



Hot Rolled 99.999% Titanium Sputtering Target CNC Machining For Solar Photovoltaic

Our Product Introduction

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Basic Information

- Place of Origin: China
- Brand Name: N/M
- Certification: ISO9001:2015 certification
- Model Number: CDX-TB-202100
- Minimum Order Quantity: 5 kg
- Price: Negotiable
- Packaging Details: plywood case
- Delivery Time: 5-35 working days
- Supply Ability: 50000KG/month



Product Specification

- Key Words: Titanium Target With Hole
- Name: Titanium Target Plate Perforated
- Application: LCD Screen, Laser Memory, Coating
- Technique: Forged,CNC Machining,Hot Rolled,Forged And CNC Machined
- Grade: Gr1
- Density: 4.51g/cm3
- Key Words 2: Pure Titanium Target
- Highlight: **Hot Rolled Titanium Sputtering Target, 99.999% Titanium Sputtering Target, Solar Photovoltaic CNC Titanium Machining**



More Images



Product Description

Titanium Target With Hole Titanium Target Plate Perforated Grade

Titanium target

High-purity and high-density sputtering targets include:

Sputtering target (purity: 99.9%-99.999%)

Titanium target plate

High-purity and high-density titanium sputtering target

Titanium target Titanium sputtering target material Used for liquid crystal display, laser memory, electronic controller, sputtering thin film material, semiconductor integrated circuit, solar photovoltaic, recording medium, flat display and surface coating of workpiece

Titanium target Titanium sputtering target material Used for liquid crystal display, laser memory, electronic controller, sputtering thin film material

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Titanium target titanium sputtering target is used for semiconductor integrated circuit, solar photovoltaic, recording medium, plane display and workpiece surface coating

Titanium round target plate titanium square target Titanium target sputter coating titanium

Titanium target with hole titanium target plate perforated

Material:	Pure titanium Gr. 1
Application:	Titanium target Titanium sputtering target material Used for liquid crystal display, electronic controller, sputtering thin film material, semiconductor integrated circuit, solar photovoltaic, recording medium, flat display and surface coating of workpiece
Purity:	99.96% - 99.99%
Custom made:	support
Tolerance:	+/-0.05mm
Shape:	round target, rectangular target

Usually we will provide a quality inspection report like this with the goods, which shows the chemical composition and physical properties

Terms of trade	EXW FOB CIF
Payment terms	T/T , L/C
packing	Plastic paper inside , plywood case outside
Delivery time	In general,the delivery time is 5 days to 35 days. Please confirm the exact delivery time with us as different products and different quantity need different delivery time.
MOQ	Small order quantity is acceptable





Q: Why choose us?

A1: We have 14 years experience for titanium products making.

A2: sample order is acceptable.

A3: lower price, good quality and short delivery time.

A4: The quotation can be made within 24 hours.

A5: ISO9001:2015 certification

A6: Give us drawing, make your drawings and ideas become a reality!

A7: Provide third-party quality inspection reports.



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